

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	2877	(laser with anneal\$4) with amorphous	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/22 09:59
L2	863	(laser with anneal\$4) with (amorphous with substrate)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/22 09:59
L3	451	2 and (laser anneal\$4 amorphous substrate) with (scanning scan\$2)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/22 10:01
L4	361	3 and irradiat\$5	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/22 10:07
L5	284	4 and grain	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/22 10:04
L6	213	4 and oscillat\$4	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/22 10:06
L7	182	6 and mirror	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/22 10:05
L10	158	7 and speed\$4	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/22 10:06
L11	105	10 and continuous	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/22 10:06
L12	105	11 and (irradiation irradiated)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/22 10:07

L13	102	12 and light	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/22 12:41
L14	1	10/671539	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/22 12:41
S40	503	(amorphous with substrate) with (scan\$2 scanning)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 09:30
S41	261	S40 and (amorphous with substrate scan\$2 scanning) with laser	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/07 14:38
S42	241	S41 and (amorphous with substrate scan\$2 scanning laser) with beam	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/07 14:38
S44	119	S42 and (amorphous with substrate scan\$2 scanning laser beam) with speed	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/07 14:45
S45	119	S42 and (amorphous with substrate scan\$2 scanning laser beam) with (speed speeding)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/08 10:56
S46	56	S45 and (amorphous with substrate scan\$2 scanning laser beam) with (spot)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/08 10:59
S47	46	S46 and (amorphous with substrate scan\$2 scanning laser beam) with (light)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/07 14:47
S48	42	S46 and (scan\$2 scanning laser beam light) with shape	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/08 10:24
S49	126368	"7" and (scan\$2 scanning laser beam light) with shape	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/08 10:24

S50	503	(amorphous with substrate) with (scan\$2 scanning)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/08 10:56
S51	261	S50 and (amorphous with substrate scan\$2 scanning) with laser	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/08 10:56
S52	241	S51 and (amorphous with substrate scan\$2 scanning laser) with beam	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/08 10:56
S53	119	S52 and (amorphous with substrate scan\$2 scanning laser beam) with (speed speeding)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/08 16:15
S54	56	S53 and (amorphous with substrate scan\$2 scanning laser beam) with (spot)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/08 10:59
S55	89	S53 and (amorphous with substrate scan\$2 scanning laser beam) with (pulse)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/08 10:59
S56	50	S55 and (amorphous with substrate scan\$2 scanning laser beam) with (intensity)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/08 11:02
S57	3	S55 and (amorphous with substrate scan\$2 scanning laser beam) with (intensity with nm)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/08 11:00
S58	0	S55 and (amorphous with substrate scan\$2 scanning laser beam) with (cross\$3 near3 hat)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/08 11:02
S59	40	S55 and (amorphous with substrate scan\$2 scanning laser beam) with (rectangular)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/08 16:13
S60	3	S55 and (amorphous with substrate scan\$2 scanning laser beam) with (hat)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/08 11:04

S61	65	S55 and (amorphous with substrate scan\$2 scanning laser beam) with (rectangular linear ellipse elliptical ellipsoid ellipsoidal oval)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/08 16:14
S62	13	S61 and (adjust adjusted adjust\$3 chang\$3) with (speed speeding)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/08 16:15
S63	14590	((amorphous (cryatalline crystalization cryatallizing cryatality crystal) with substrate)) with (laser)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 09:55
S64	7038	(amorphous cryatalline crystalization cryatallizing cryatality crystal substrate) with (laser with (scanning scan\$3))	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 09:35
S65	5921	S64 and (beam) with (laser scanning scan\$3)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 09:35
S66	2193	S65 and (spot sharpe) with (beam laser scanning scan\$3)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 09:36
S67	964	S66 and (irradiating irradiat\$2) with (beam laser scanning scan\$3)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 09:37
S68	453	S67 and (irradiating irradiat\$2 beam laser scanning scan\$3) with (oscillation oscillator oscillat\$3)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 09:39
S69	354	S68 and (irradiating irradiat\$2 beam laser scanning scan\$3) with (linear rectangular ellipse elliptical ellipsoidal)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 09:40
S70	287	S69 and (irradiating irradiat\$2 beam laser scanning scan\$3 linear rectangular ellipse elliptical ellipsoidal) with speed	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 09:41

S71	106	S69 and (adjusted adjust\$3 control\$2 controlling change\$ changing) with speed	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 11:53
S72	14659	((amorphous (cryatalline crystalization crystallizing crystalinity crystal) with substrate)) with (laser)	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 09:55
S73	1	10/671539	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 12:10
S74	1	(laser near3 annealling) with amorphous	US-PGPU B; USPAT; EPO; JPO	OR	ON	2005/11/09 12:11